Semiconductor Device Physics

Lecture 5

http://zitompul.wordpress.com

Direct and Indirect Semiconductors

- **Little change in momentum is required for recombination**
- **Momentum is conserved by photon (light) emission**

- **Large change in momentum is required for recombination**
- **Momentum is conserved by mainly phonon (vibration) emission + photon emission**

Excess Carrier Concentrations

Positive deviation Δn , $\Delta p > 0$ corresponds to a carrier excess, while negative deviation $\Delta n, \Delta p < 0$ corresponds to a carrier deficit.

■ Charge neutrality condition:

$$
\Delta n = \Delta p
$$

"Low-Level Injection"

 $\Delta n >> n_{0}$

- Often, the disturbance from equilibrium is small, such that the majority carrier concentration is not affected significantly.
- However, the minority carrier concentration can be significantly affected.
	- For an *n*-type material $\Delta p \ll n_0$, $n \approx n_0$ $\Delta p \gg p_0$ $\Delta p >> p_{_0}$
	- **For a p-type material** $\Delta n \ll p_0$, $p \approx p_0$ $\Delta n \gg n_0$

- **This condition is called "low-level injection condition".**
- The *workhorse* of the diffusion in low-level injection condition is the minority carrier (which number increases significantly) while the majority carrier is practically undisturbed.

Photoconductor

- **Photoconductivity** is an optical and electrical phenomenon in which a material becomes more electrically conductive due to the absorption of electro-magnetic radiation such as visible light, ultraviolet light, infrared light, or gamma radiation.
- When light is absorbed by a material like semiconductor, the number of free electrons and holes changes and raises the electrical conductivity of the semiconductor.
- To cause excitation, the light that strikes the semiconductor must have enough energy to raise electrons across the band gap.

Example: Photoconductor

■ Consider a sample of Si at 300 K doped with 10^{16} cm⁻³ Boron, with recombination lifetime 1 *μ*s. It is exposed continuously to light, such that electron-hole pairs are generated throughout the sample at the rate of 10²⁰ per cm³ per second, *i.e.* the **generation rate** $G_{L} = 10^{20}$ **/cm³/s.**

a) What are p_0 and n_0 ?

$$
p_0 = 10^{16} \text{cm}^{-3}
$$

$$
n_0 = \frac{n_i^2}{p_0} = \frac{\left(10^{10}\right)^2}{10^{16}} = 10^4 \text{cm}^{-3}
$$

b) What are Δ*n* and Δ*p*?

 $\Delta p = \Delta n$ = $G_L \cdot \tau$ = $10^{20} \times 10^{-6}$ = 10^{14} cm⁻³

• **Hint: In steady-state (equilibrium), generation rate equals recombination rate**

Example: Photoconductor

■ Consider a sample of Si at 300 K doped with 10^{16} cm⁻³ Boron, with recombination lifetime 1 μ s. It is exposed continuously to light, such that electron-hole pairs are generated throughout the sample at the rate of 10²⁰ per cm³ per second, *i.e.* the **generation rate** $G_{L} = 10^{20}$ **/cm³/s.**

c) What are *p* and *n*?

$$
p = p_0 + \Delta p = 10^{16} + 10^{14} \approx 10^{16} \text{cm}^{-3}
$$

$$
n = n_0 + \Delta n = 10^4 + 10^{14} \approx 10^{14} \text{ cm}^{-3}
$$

d) What are *np* product?

$$
np \approx 10^{16} \cdot 10^{14} = 10^{30} \text{ cm}^{-3} \gg n_i^2
$$

• **Note: The** *np* **product can be very different from** *n***ⁱ 2 in case of perturbed / agitated semiconductor**

Continuity Equation

■ Consider carrier-flux into/out of an infinitesimal volume:

$$
Adx \cdot \left(\frac{\partial n}{\partial t}\right) = \frac{1}{q} \left[\mathbf{J}_{N}(x+dx) - \mathbf{J}_{N}(x) \right] A
$$

Continuity Equation

$$
\mathbf{J}_{N}(x+dx) = \mathbf{J}_{N}(x) + \frac{\partial \mathbf{J}_{N}(x)}{\partial x} dx
$$

$$
\frac{\partial n}{\partial t} = \frac{1}{q} \frac{\partial \mathbf{J}_{N}(x)}{\partial x}
$$

• **Taylor's Series Expansion**

The Continuity Equations

$$
\frac{\partial n}{\partial t} = \frac{1}{q} \frac{\partial \mathbf{J}_N(x)}{\partial x} + \frac{\partial n}{\partial t}\Big|_{\text{thermal}} + \frac{\partial n}{\partial t}\Big|_{\text{other}}
$$
\n
$$
\frac{\partial p}{\partial t} = -\frac{1}{q} \frac{\partial \mathbf{J}_P(x)}{\partial x} + \frac{\partial p}{\partial t}\Big|_{\text{thermal}} + \frac{\partial p}{\partial t}\Big|_{\text{other}}
$$
\n
$$
\frac{\partial p}{\partial t} = -\frac{1}{q} \frac{\partial \mathbf{J}_P(x)}{\partial x} + \frac{\partial p}{\partial t}\Big|_{\text{thermal}} + \frac{\partial p}{\partial t}\Big|_{\text{other}}
$$

Minority Carrier Diffusion Equation

- **The minority carrier diffusion equations are derived from the** general continuity equations, and are applicable only for minority carriers.
- Simplifying assumptions:
	- **The electric field is small, such that:**

$$
\mathbf{J}_{\mathrm{N}} = q\mu_{\mathrm{n}}n\mathbf{\mathcal{E}} + qD_{\mathrm{N}}\frac{\partial n}{\partial x} \approx qD_{\mathrm{N}}\frac{\partial n}{\partial x}
$$

• **For** *p***-type material**

$$
J_{\rm P} = q\mu_{\rm p}p\mathcal{E} - qD_{\rm P}\frac{\partial p}{\partial x} \approx -qD_{\rm P}\frac{\partial p}{\partial x}
$$

- **For** *n***-type material**
- **Equilibrium minority carrier concentration** n_0 **and** p_0 **are** independent of *x* (uniform doping).
- **Low-level injection conditions prevail.**

Minority Carrier Diffusion Equation

■ Starting with the continuity equation for electrons:

$$
\frac{\partial n}{\partial t} = \frac{1}{q} \frac{\partial \mathbf{J}_N(x)}{\partial x} - \frac{\Delta n}{\tau_n} + G_L
$$
\n
$$
\frac{\partial (n_0 + \Delta n)}{\partial t} = \frac{1}{q} \frac{\partial}{\partial x} \left[qD_N \frac{\partial (n_0 + \Delta n)}{\partial x} \right] - \frac{\Delta n}{\tau_n} + G_L
$$
\n
$$
\frac{\partial n}{\partial t} \bigg|_{\text{other}} = G_L
$$
\n
$$
\frac{\partial n}{\partial t} \bigg|_{\text{other}} = G_L
$$

■ The **minority carrier lifetime** *τ* is the average time for excess minority carriers to "survive" in a sea of majority carriers.

2 $N \sim 2$ C_{L} n $\frac{n}{q} = D_{\rm M} \frac{C \Delta n}{r} - \frac{\Delta n}{r} + G_{\rm G}$ *t* ∂x^2 τ $\partial \Delta n$ $=$ $\partial^2 \Delta n$ Δ $= D_{\rm M}$ - - - - + ∂t ∂ 2 $P_{\rm P}$ $\frac{1}{2r^2}$ $\frac{1}{\tau}$ + $G_{\rm L}$ p $\frac{p}{p} = D_p \frac{\partial^2 \Delta p}{\partial x^2} - \frac{\Delta p}{p} + G_p$ $\frac{dP}{dt} = D_{\rm p} \frac{\partial^2 P}{\partial x^2} - \frac{\partial^2 P}{\partial x^2}$ $\overline{\partial \Delta p}$ $\overline{\Delta p}$ $\overline{\partial^2 \Delta p}$ $\overline{\Delta p}$ $= D_{\rm p} \frac{\partial^2 \Delta p}{\partial^2} - \frac{\Delta p}{\partial^2} + G_{\rm L}$ $\frac{\Delta p}{\partial t} = D_{\rm p} \frac{\partial \Delta p}{\partial x^2}$ **Therefore Similarly**

Carrier Concentration Notation

- The subscript "n" or "p" is now used to explicitly denote n-type or *p*-type material*.*
	- p_n is the hole concentration in *n*-type material
	- $n_{\rm p}$ is the electron concentration in *p*-type material

Thus, the minority carrier diffusion equations are:

$$
\frac{\partial \Delta n_{\rm p}}{\partial t} = D_{\rm N} \frac{\partial^2 \Delta n_{\rm p}}{\partial x^2} - \frac{\Delta n_{\rm p}}{\tau_{\rm n}} + G_{\rm L}
$$

$$
\frac{\partial \Delta p_{\rm n}}{\partial t} = D_{\rm p} \frac{\partial^2 \Delta p_{\rm n}}{\partial x^2} - \frac{\Delta p_{\rm n}}{\tau_{\rm p}} + G_{\rm L}
$$

- **Partial Differential Equation (PDE)!**
- **The so called "Heat Conduction Equation"**

Simplifications (Special Cases)

Steady state:

$$
\frac{\partial \Delta n_{\rm p}}{\partial t} = 0, \quad \frac{\partial \Delta p_{\rm n}}{\partial t} = 0
$$

No diffusion current:

$$
D_{\rm N} \frac{\partial^2 \Delta n_{\rm p}}{\partial x^2} = 0, \quad D_{\rm P} \frac{\partial^2 \Delta p_{\rm n}}{\partial x^2} = 0
$$

■ No thermal R–G:

$$
\frac{\Delta n_{\rm p}}{\tau_{\rm n}} = 0, \quad \frac{\Delta p_{\rm n}}{\tau_{\rm p}} = 0
$$

 \blacksquare No other processes: $G_{\rm L} = 0$

• **Solutions for these common special-case diffusion equation are provided in the textbook**

Minority Carrier Diffusion Length

■ Consider the special case:

■ Constant minority-carrier (hole) injection at *x* = 0 ■ Steady state, no light absorption for *x* > 0

Let The **hole diffusion length** $L_{\rm p}$ is defined to be: $L_{\rm p} = \sqrt{D_{\rm p} \tau_{\rm p}}$ Similarly, $L_{\text{N}} = \sqrt{D_{\text{N}}}\tau_{\text{n}}$

Minority Carrier Diffusion Length

 $\partial^2 \Delta p$ Δ

 $\overline{\partial x^2}$ =

n n 2 2

 $p_{\rm n}$ Δp

 x^2 *L*

P

2

 \blacksquare The general solution to the equation

$$
\Delta p_{n}(x) = Ae^{-x/L_{\rm P}} + Be^{x/L_{\rm P}}
$$

■ *A* and *B* are constants determined by boundary conditions:

$$
\Delta p_{n}(\infty) = 0 \implies B = 0
$$

$$
\Delta p_{n}(0) = \Delta p_{n0} \implies A = \Delta p_{n0}
$$

Therefore, the solution is:

$$
\Delta p_{n}(x) = \Delta p_{n0} e^{-x/L_{\rm P}}
$$

• Physically, L_{P} and L_{N} represent the **average distance that a minority carrier can diffuse before it recombines with a majority carrier.**

Example: Minority Carrier Diffusion Length

■ Given $N_{D}=10^{16}$ cm⁻³, $\tau_{p}=10^{-6}$ s. Calculate L_{p} .

Quasi-Fermi Levels

- Whenever $\Delta n = \Delta p \neq 0$ then $np \neq n_i²$ and we are at nonequilibrium conditions.
- \blacksquare In this situation, now we would like to preserve and use the relations:

$$
n=n_{\mathrm{i}}e^{(E_{\mathrm{F}}-E_{\mathrm{i}})/kT},\quad p=n_{\mathrm{i}}e^{(E_{\mathrm{i}}-E_{\mathrm{F}})/kT}
$$

- **On the other hand, both equations imply** $np = n_i²$ **, which does** not apply anymore.
- The solution is to introduce to quasi-Fermi levels F_N and F_P such that:

$$
n = n_{i}e^{(F_{N}-E_{i})/kT}
$$

\n
$$
p = n_{i}e^{(E_{i}-F_{P})/kT}
$$

\n
$$
F_{P} = E_{i} - kT \ln \left(\frac{p}{n_{i}}\right)
$$

• **The quasi-Fermi levels is useful to describe the carrier concentrations under non-equilibrium conditions**

Example: Quasi-Fermi Levels

Consider a Si sample at 300 K with $N_D = 10^{17}$ cm⁻³ and $Δ*n* = Δ*p* = 10¹⁴ cm⁻³.$

a) What are *p* and *n*? The sample is an *n*-type
\n
$$
n_0 = N_D = 10^{17} \text{ cm}^{-3}, \ p_0 = \frac{n_i^2}{n_0} = 10^3 \text{ cm}^{-3}
$$
\n
$$
n = n_0 + \Delta n = 10^{17} + 10^{14} \approx 10^{17} \text{ cm}^{-3}
$$
\n
$$
p = p_0 + \Delta p = 10^3 + 10^{14} \approx 10^{14} \text{ cm}^{-3}
$$

 $np \thickapprox 10^{17} \cdot 10^{14} \!=\! 10^{31} \mathrm{cm}^{-3}$ b) What is the *np* product?

Example: Quasi-Fermi Levels

Consider a Si sample at 300 K with $N_D = 10^{17}$ cm⁻³ and $Δ*n* = Δ*p* = 10¹⁴ cm⁻³.$

c) Find F_N and F_P ? $F_{\rm N} = E_{\rm i} + kT \ln(n/n_{\rm i})$ $F_{\rm N}$ – $E_{\rm i}$ = 8.62×10⁻⁵ · 300 · ln $(10^{17}/10^{10})$ $=0.417 \; \text{eV}$

$$
F_{\rm p} = E_{\rm i} - kT \ln (p/n_{\rm i})
$$
\n
$$
E_{\rm i} - F_{\rm p} = 8.62 \times 10^{-5} \cdot 300 \cdot \ln (10^{14}/10^{10})
$$
\n
$$
= \underbrace{0.238 \text{ eV}}_{= 1.000257 \times 10^{31}} = 1.000257 \times 10^{31}
$$
\n
$$
F_{\rm i} - F_{\rm p} = 8.62 \times 10^{-5} \cdot 300 \cdot \ln (10^{14}/10^{10})
$$
\n
$$
= 1.000257 \times 10^{31}
$$

$$
np = n_{i}e^{(F_{N}-E_{i})/kT} \cdot n_{i}e^{(E_{i}-F_{P})/kT}
$$

= $10^{10}e^{\frac{0.417}{0.02586}} \cdot 10^{10}e^{\frac{0.238}{0.02586}}$
= 1.000257×10^{31}
 $\approx 10^{31} \text{cm}^{-3}$